

ACCESS ACKNOWLEDGMENT

and

SECURITY ORDER RECOMMENDATION BY DEFENSE AGENCY

Application Serial No.: 10/811,257

Defense Agency: ARMY

Filing Date:

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Date Created:

I hereby acknowledge as indicated by my signature on this form that I have inspected this application in administration of 35 USC 181 on behalf of the Agency/Command specified below. I promise not to divulge any information from this application for any purpose other than administration of 35 USC 181.

Recommendation

(e.g. 'Secrecy Not Recommended (SNR)')

Reviewer(s) Signature/Date/Command

	<p><i>Alsu P. Allen</i> SNR 6-15-04</p> <p>JUN 15 2004</p> <p>U.S. Army</p> <p>CONCOM NASA</p> <p>RECEIVED JUL - 9 2004 LICENSING & REVIEW</p>
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Instructions to Reviewers:

1. All individuals reviewing this application are required under 35 USC 181 to sign and date this form regardless of whether they are making a secrecy order recommendation.
2. The attached copy of the application, any copies made therefrom and this form must be returned to the PTO once a recommendation not to impose secrecy has been made or a secrecy order has been rescinded.

Notice for Completion of Review:

Pursuant to 35 U.S.C. 184, the subject matter of this application may be filed in a foreign country for the purpose of filing a patent application without a license any time after the expiration of 6 months from filing date unless the application becomes the subject of a secrecy order.

35 USC 181 (a) (1) (A) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (A) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (B) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (C) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (D) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (E) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (F) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (G) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (H) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (I) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (J) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (K) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (L) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (M) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (N) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (O) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (P) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (Q) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (R) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (S) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (T) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (U) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (V) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (W) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (X) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (Y) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States. (b) (1) (Z) provides that an application for a patent shall not be published in the United States or any other country for a period of 18 months from the date of filing of the application in the United States.